

MAY 24 2004

**TRANSMITTAL OF FORMAL DRAWINGS**

Docket No.  
SLA0673

In Re Application Of: Tingkai Li, Sheng Teng Hsu, David R. Evans and Bruce D. Ulrich

Serial No.	Filing Date	Batch No.	Examiner	Art Unit
10/606,057	06/25/2003		Walter Lee Lindsay Jr.	2812

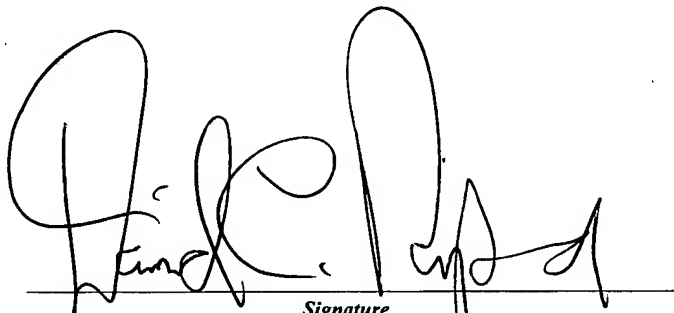
Invention: MOCVD Selective Deposition of C-Axis Oriented Pb5Ge3O11 Thin Films on High k Gate Oxides

Address to:  
Assistant Commissioner for Patents  
Washington, D.C. 20231

Transmitted herewith are:

2 sheets of formal drawing(s) for this application.

Each sheet of drawing indicates the identifying indicia suggested in 37 CFR Section 1.84(c) on the reverse side of the drawing.



*Signature*

David C. Ripma, Patent Counsel  
Registration No. 27,672  
Sharp Laboratories of America, Inc.  
5750 NW Pacific Rim Boulevard  
Camas, WA 98607  
Phone: 360-834-8754  
Facsimile: 360-817-8505

Dated: May 21, 2004

I certify that this document and attached formal drawings are being deposited on May 21 2004 with the U.S. Postal Service as first class mail under 37 C.F.R. 1.8 and addressed to the Assistant Commissioner for Patents, Washington, D.C. 20231.

*Signature of Person Mailing Correspondence*

David C. Ripma, Reg. #27,672

*Typed or Printed Name of Person Mailing Correspondence*